



EUROPEAN PATENT APPLICATION

Application number : **91306888.8**

Int. Cl.⁵ : **H01L 29/72**

Date of filing : **26.07.91**

Priority : **03.08.90 US 562470**

Inventor : **Cavanaugh, Marion Eugene**
792 Paul Avenue
Palo Alto, California 94306 (US)

Date of publication of application :
05.02.92 Bulletin 92/06

Representative : **Cross, Rupert Edward Blount**
et al
BOULT, WADE & TENNANT 27 Furnival Street
London EC4A 1PQ (GB)

Designated Contracting States :
DE FR GB NL

Date of deferred publication of search report :
28.10.92 Bulletin 92/44

Applicant : **Cavanaugh, Marion Eugene**
792 Paul Avenue
Palo Alto, California 94306 (US)

Quantum field effect device.

A Semiconductor device having at least three terminals and a single PN junction using quantum-effect tunneling for the primary conduction mode comprises a substrate or well (22) of a first conductivity type, a source region (12) of said first conductivity type and a drain region (10) of a second conductivity type. A further region (18) of a first conductivity type is provided between source (12) and drain (10) regions and forms a PN junction with said drain region (10). Conductance through said PN junction in the tunneling mode is controlled by changing the junction depletion width by means of a MOS gate electrode (14,20) formed on said region (18). A Schottky gate device, a bidirectional device and a complementary device are further disclosed.

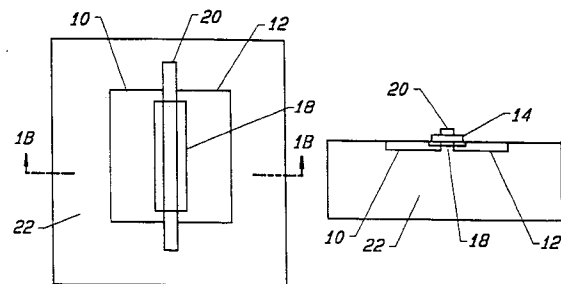


FIG. 1A

FIG. 1B



European Patent
Office

EUROPEAN SEARCH REPORT

Application Number

EP 91 30 6888

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
X	FR-A-2 607 630 (E. ROSENCHER) * the whole document * ---	1	H01L29/72
X,P	US-A-4 969 019 (TEXAS INSTRUMENTS INCORPORATED) * the whole document * ---	1	
X	IBM TECHNICAL DISCLOSURE BULLETIN. vol. 25, no. 6, November 1982, NEW YORK US pages 2930 - 2931; A.B.FOWLER: 'GATED TUNNEL DIODES' * the whole document * ---	1	
X	IBM TECHNICAL DISCLOSURE BULLETIN. vol. 16, no. 7, December 1973, NEW YORK US page 2303; W.FISCHER: 'FIELD INDUCED DIODE' * the whole document * -----	1	
The present search report has been drawn up for all claims			TECHNICAL FIELDS SEARCHED (Int. Cl.5)
			H01L
Place of search THE HAGUE		Date of completion of the search 17 AUGUST 1992	Examiner PELSERS L.
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document		I : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons ----- & : member of the same patent family, corresponding document	

EPO FORM 1503 03.82 (P0401)